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Electronic supplementary information

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3 **Robust Dihydroxyacetone Production via Photoelectrochemical**
4 **Glycerol Oxidation using Oxygen Vacant BiVO₄ Photoanode**

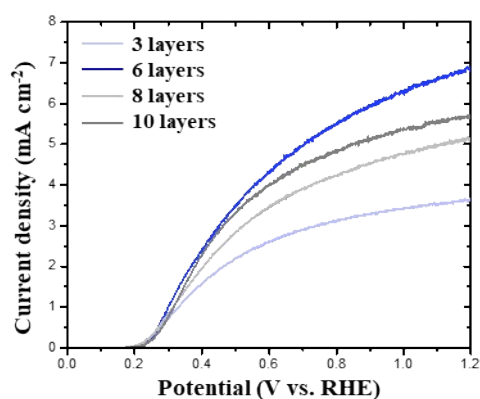
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8 [‡] Yeji Lee and Yeseul Jo contributed equally to this work.

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11 **Fig. S1** Photoelectrochemical J-V characteristics of BiVO₄ in different cycles in 0.5 M Na₂SO₃ with 0.1 M borate
 12 buffer (pH 9.3, adjusted by 0.1M NaOH).

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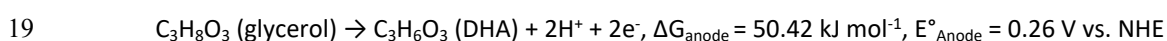
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15 **Table S1** Calculation of theoretical redox potential for glycerol to DHA.¹

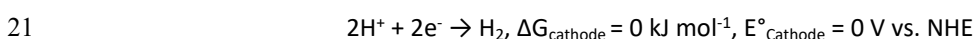
ΔG_f (C ₃ H ₈ O ₃) (kJ mol ⁻¹)	ΔG_f (C ₃ H ₆ O ₃) (kJ mol ⁻¹)	E° _{Anode} (V vs. NHE)	E° _{Cathode} (V vs. NHE)
-478.6	-428.18	0.26	0

16 Standard Gibb's free energy and redox potential of reaction for the GOR to DHA coupled with the HER were
 17 calculated based on the above data.

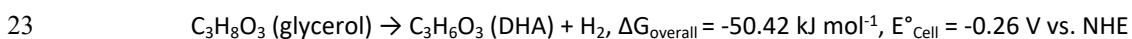
18 For anode reaction (GOR):



20 For cathode reaction (HER):



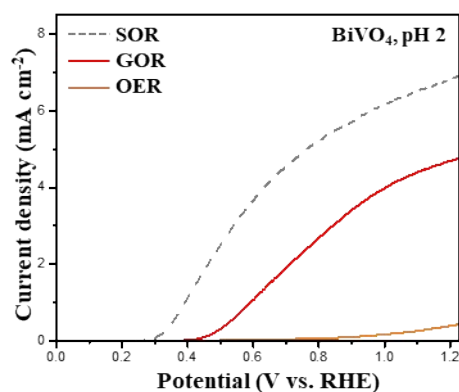
22 For overall reaction using E°_{Cell} = E°_{Cathode} - E°_{Anode}



24 Equation $\Delta G^\circ = nFE^\circ_{Cell}$ is used to calculate E°_{Cell}, where n is the number of electrons transferred and F is the
 25 Faraday constant (96485 C mol⁻¹). All thermodynamic properties are reported under standard conditions (1 bar
 26 and 298 K).

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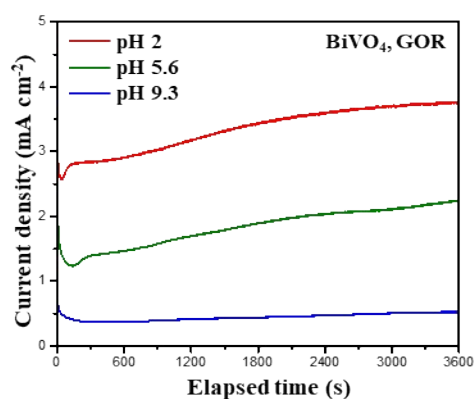


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30 **Fig. S2** Photoelectrochemical J-V characteristics of BiVO₄ in different oxidation reactions at pH 2.

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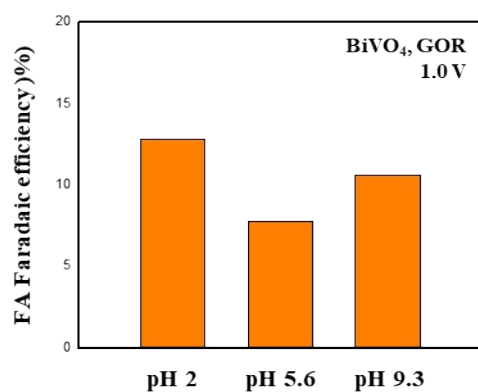


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34 **Fig. S3** Chronoamperometric curves on BiVO₄ in 0.5 M Na₂SO₄ with 0.1 M glycerol under 1.0 V vs. RHE at pH 2,
35 pH 5.6, and pH 9.3.

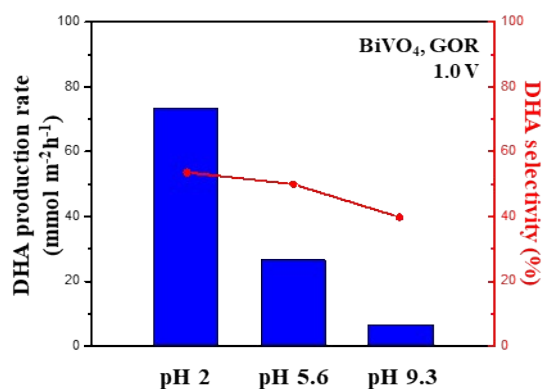
36 The J-t curves in Fig. S3 demonstrated that photocurrent density initially decreased after first illumination at
37 pH 2 pH 5.6, and pH 9.3, which can be attributed to the accumulation of holes at the BiVO₄ surface and the
38 relatively slow interfacial charge transfer compared to charge recombination.² As the illumination progresses,
39 the photocurrent density gradually increased, resulting from time-dependent photoactivation during water
40 and glycerol oxidation.³

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43 **Fig. S4** FEs of FA under 1.0 V vs. RHE at pH 2, pH 5.6, and pH 9.3.

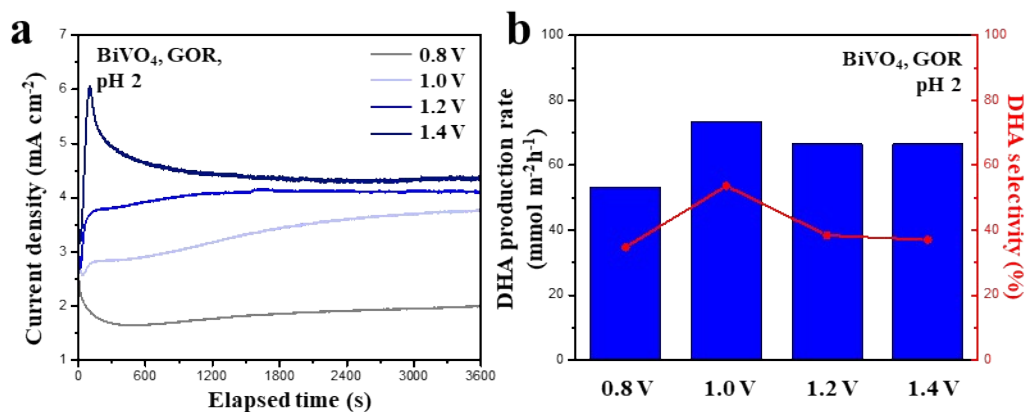


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45 **Fig. S5** Production rates and selectivities of DHA under 1.0 V vs. RHE at pH 2, pH 5.6, and pH 9.3.

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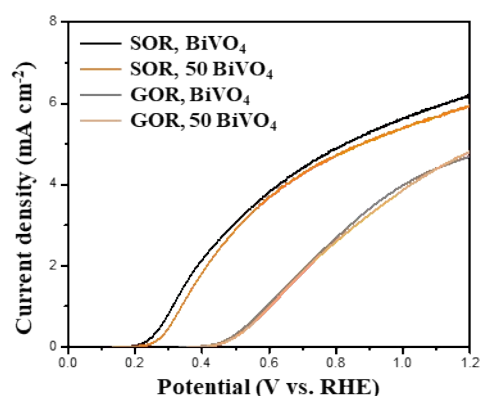
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49 **Fig. S6** (a) Chronoamperometric curves on BiVO₄, and (b) Production rates and selectivities of DHA at pH 2
50 under 0.8, 1.0, 1.2, and 1.4 V vs. RHE.

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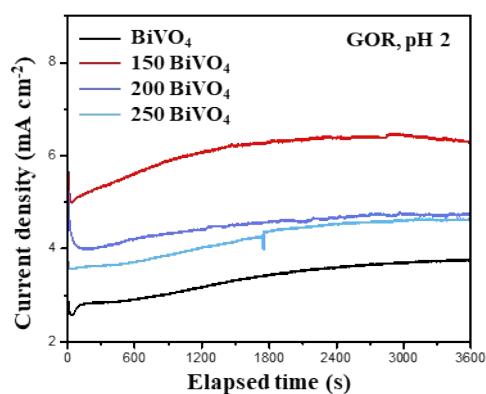
53 **Fig. S7** Photoelectrochemical J-V characteristics of BiVO_4 and 50 BiVO_4 for sulfite oxidation (pH 9.3) and
 54 glycerol oxidation (pH 2).

55 A thermal treatment below 150°C was insufficient for modifying BiVO_4 , as it exerted minimal influence on the
 56 formation of oxygen vacancies, bulk efficiency of BiVO_4 , and the charge transfer dynamics for glycerol
 57 oxidation.

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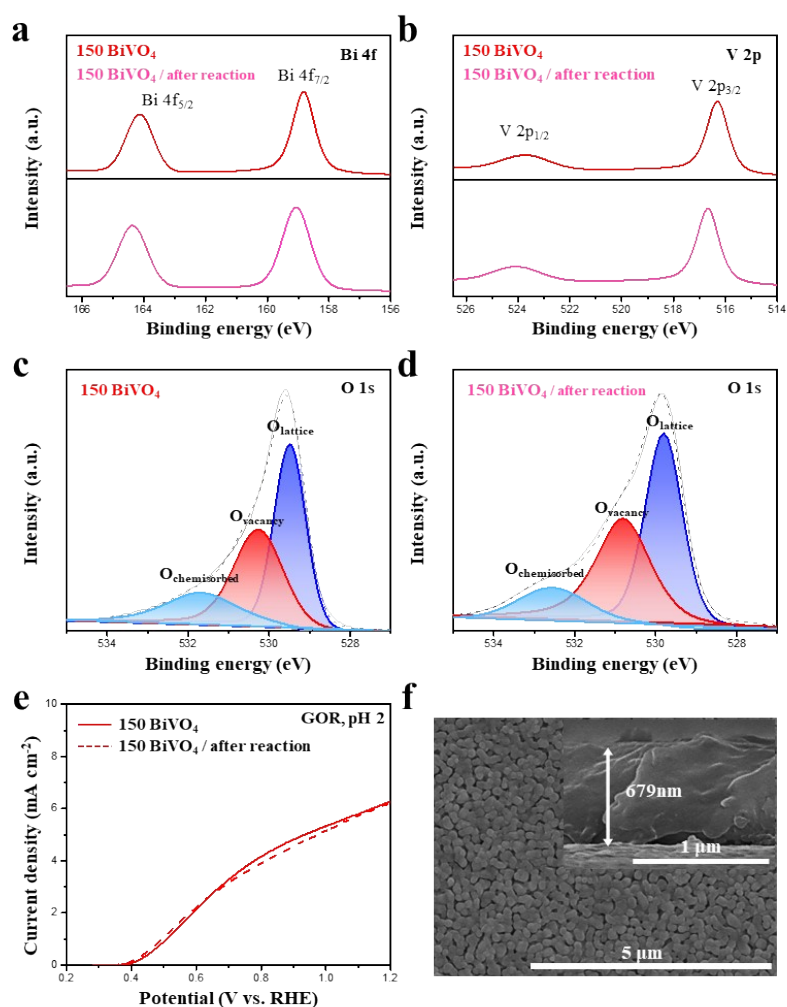


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62 **Fig. S8** Chronoamperometric curves on BiVO_4 and $X \text{ BiVO}_4$ ($X=\text{N}_2$ -annealing temperature) in $0.5 \text{ M Na}_2\text{SO}_4$ with
 63 0.1 M glycerol under 1.0 V vs. RHE at pH 2.

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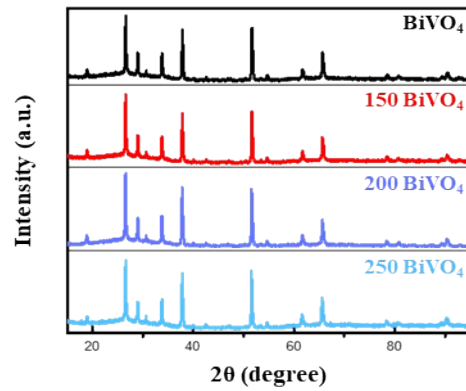
67 **Fig. S9** Analysis of 150 BiVO₄ before and after glycerol oxidation at pH 2 under 1.0 V vs. RHE for 1 hour (Fig. S8).
 68 XPS spectra of (a) Bi 4f, (b) V 2p, and (c-d) O 1s for 150 BiVO₄. (e) Photoelectrochemical J-V curves of 150 BiVO₄
 69 before and after reaction. (f) FE-SEM image of 150 BiVO₄ after reaction.

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71 Following a chronoamperometric measurement for 1 hour on 150 BiVO₄ for glycerol oxidation under 1.0 V vs.
 72 RHE at pH 2, XPS results showed no new shoulder peaks for Bi 4f, V 2p, and O 1s, confirming that the
 73 composition of BiVO₄ remained well-preserved (Fig. S9(a-d)). J-V analysis was conducted to assess glycerol
 74 oxidation performance for 150 BiVO₄ after reaction for 1 hour, with no changes observed (Fig. S9(e)). Also, the
 75 condensed morphology with minor pores between crystallites was preserved, showing no significant signs of
 76 corrosion or degradation compared to the 150 BiVO₄ before the reaction (Fig. S9(f)).

77 As a result, the chemical states of the elements constituting BiVO₄ were preserved, indicating that the
 78 oxidation reaction for 1 hour did not cause significant damage to the BiVO₄ film. Additionally, the Pourbaix
 79 diagram of BiVO₄ indicates that BiVO₄ film remains in a stable solid-state, maintaining its integrity in
 80 an aqueous solution under 1.0 V vs. RHE at pH 2.⁴ Meanwhile, the slight decrease observed in
 81 the chronoamperometric curve of 150 BiVO₄ after 3000 s is attributed to changes in the distribution and
 82 concentration gradients of reactants and products within the electrolyte.

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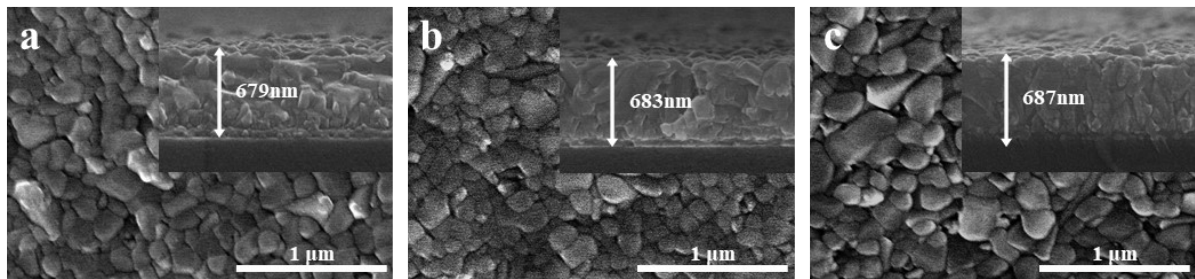


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85 **Fig. S10** XRD patterns of BiVO_4 and $X \text{ BiVO}_4$.

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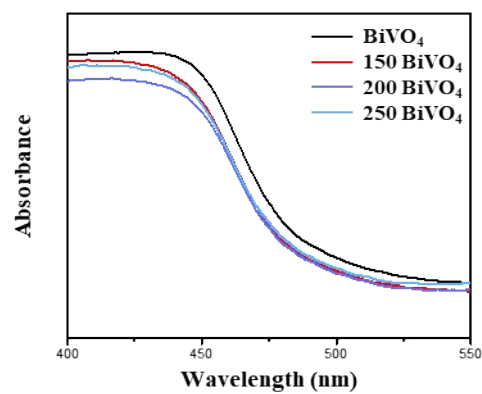


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89 **Fig. S11** FE-SEM images of top-view of (a) 150 BiVO_4 , (b) 200 BiVO_4 , and (c) 250 BiVO_4 . The inset images show
90 the corresponding cross-sectional image.

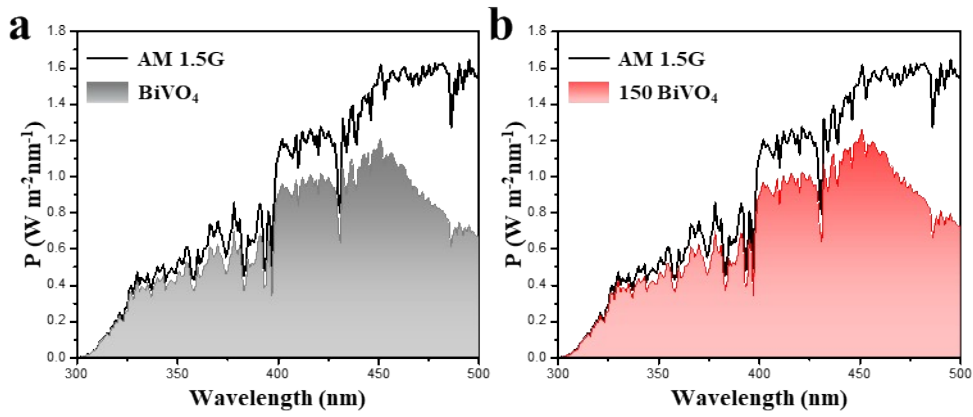
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94 **Fig. S12** visible absorbance spectra of BiVO_4 and $X \text{ BiVO}_4$.



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96 **Fig. S13** Power of light provided by the solar simulator and light absorbed by (a) BiVO₄ and (b) 150 BiVO₄.^{5,6}

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99 **Table S2** Slope, x-axis intercept, carrier density, and Flat Band potential of BiVO₄ and 150 BiVO₄ calculated by
100 the Mott-Schottky method.⁷

	Slope	x-axis intercept	N _D (cm ⁻³)	V _{FB} (V vs. RHE)
BiVO₄	1.202 × 10 ¹³	0.194	5.87 × 10 ¹⁸	0.168
150 BiVO₄	6.147 × 10 ¹²	0.178	1.15 × 10 ¹⁹	0.153

101 Flat band potential (V_{FB}) and carrier density (N_D) of photoanode was calculated based on Mott-Schottky
102 equation

$$103 \quad \frac{1}{C^2} = \frac{2}{\epsilon\epsilon_0 q N_D A^2} \left(V - V_{FB} - \frac{k_B T}{q} \right)$$

$$104 \quad N_D = \frac{2}{\epsilon\epsilon_0 q A^2 (\text{slope})}$$

$$105 \quad V_{FB} = x - \text{axis intercept} - \frac{K_B T}{q}$$

106 where ϵ is the semiconductor dielectric constant (32 for BiVO₄), ϵ_0 is the vacuum permittivity constant (8.85 ×
107 10⁻¹⁴ F cm⁻¹), q is the elementary charge (1.602 × 10⁻¹⁹ C), A is the electrode area (0.25 cm²), k_B is the
108 Boltzmann constant (1.38 × 10⁻²³ J K⁻¹), and T is the absolute temperature (298 K).

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115 **Table S3** Energy levels of BiVO₄ and 150 BiVO₄ calculated by UPS measurements.^{8,9}

	E_{cutoff} (eV)	E_{onset} (eV)	VBM (eV)	CBM (eV)	WF (eV)
BiVO₄	17.4	1.8	5.62	3.1	3.82
150 BiVO₄	17.7	2.2	5.72	3.19	3.52

116 To identify the energy level alignment of the photoanode, the ultraviolet photoelectron spectroscopy (UPS)
 117 measurements were carried out on BiVO₄ and 150 BiVO₄. The cutoff energy and onset energy were obtained
 118 by linearly extrapolating the high binding energy and low binding energy, respectively. The valence band
 119 maximum (VBM) can be computed using the following equation

120
$$VBM = hv - (E_{cutoff} - E_{onset})$$

121 Where $hv = 21.22$ eV is the incident photo energy from a He (I) source of UPS systems. The conduction band
 122 minimum (CBM) was deduced from bandgap and VBM. The work function (WF) was calculated using the
 123 following formulation

124
$$WF = E_{vacuum} - E_F = hv - E_{cutoff}$$

125 Where E_F is the Fermi-level. Finally, the relationship between the vacuum energy (V vs. vacuum) and the
 126 normal electrode potential (V vs. NHE) was provided by $E_{vacuum} = -E_{NHE} - 4.44$.

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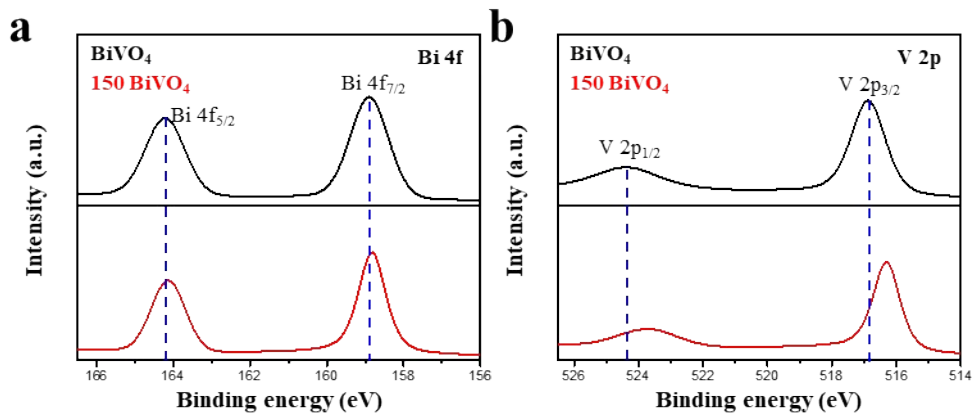
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129 **Table S4** O 1s peak fitting results obtained from XPS analysis.

Sample	Oxygen Atomic % (At.%)	O_{lattice}		O_{vacancy}		O_{chemisorbed}	
		BE (eV)	Area (%)	BE (eV)	Area (%)	BE (eV)	Area (%)
BiVO₄	56.1	529.4	56.6	530.4	21.2	531.6	22.2
150 BiVO₄	60.02	529.5	44.3	530.3	37.3	531.7	18.4

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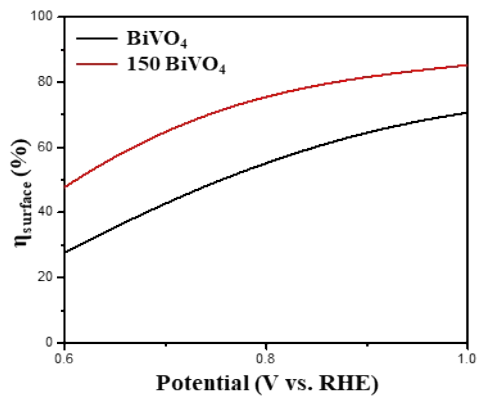


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133 **Fig. S14** XPS of (a) Bi 4f spectra and (b) V 2p spectra for BiVO₄ and 150 BiVO₄.

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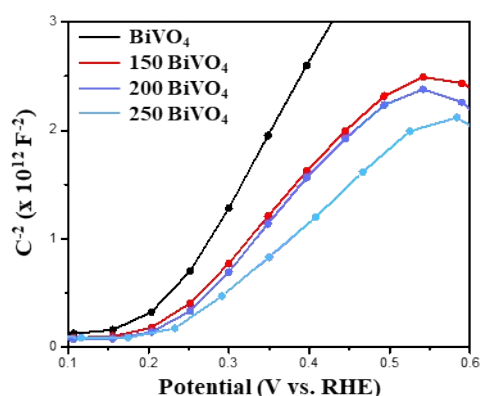
137 **Fig. S15** Surface charge injection efficiencies of the BiVO₄ and 150 BiVO₄.

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143 **Fig. S16** Mott-Schottky plots of BiVO_4 and $X \text{BiVO}_4$.

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146 **Table S5** Summary table of the recent advances in photoelectrochemical glycerol oxidation to
 147 dihydroxyacetone (DHA).

Photoanode	Electrolyte	Potential (V vs. RHE)	Production rate ($\text{mmol m}^{-2}\text{h}^{-1}$)	FE (%)	Sel (%)	Ref.
{010}-BiVO_4	0.1M $\text{Na}_2\text{B}_4\text{O}_7$ with 0.1M glycerol (pH 2)	1.1	90	-	60	10
MP-BiVO_4	0.5M Na_2SO_4 with 0.1M glycerol (pH 2)	1.23	352.2	29.1	53.7	11
$\text{BiVO}_4/\text{NiCo-LDH-Act}$	0.5M Na_2SO_4 with 0.6M glycerol (pH 2)	1.4	205	-	41.93	12
$\text{WO}_3/\text{BiVO}_4/\text{Bi}$	0.5M Na_2SO_4 with 0.1M glycerol (pH 2)	1.2	192.69	35.3	60.6	13
Bi rich-$\text{BiVO}_{(4-x)}$	0.5M Na_2SO_4 with 0.1M glycerol (pH 2)	1.23	361.9	46	80.3	14
$\text{BiVO}_4/\text{CoO}_x/\text{Au}$	0.5M Na_2SO_4 with 0.1M glycerol (pH 2)	1.2	339.74	40	60	15
B:$\text{NiCoO}_x:\text{BiVO}_4$	0.5M Na_2SO_4 with 0.1M glycerol (pH 2)	1.23	228.4	34.3	30.8	16
$\text{N}_2\text{-BiVO}_4$	0.5M Na_2SO_4 with 0.1M glycerol (pH 2)	1.0	160	14	50.5	This work

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